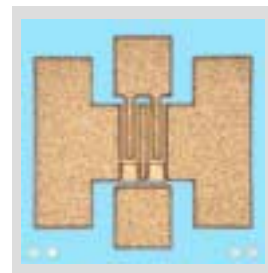


Super Low Noise GaAs FETs

FEATURES

- Low Noise Figure: NF = 0.5 dB Typical at 12 GHz
- High Associated Gain: Ga = 12 dB Typical at 12 GHz
- $L_g = 0.25 \mu\text{m}$, $W_g = 300 \mu\text{m}$
- All-Gold Metallization for High Reliability
- Tight V_p ranges control
- High RF input power handling capability
- 100 % DC Tested

PHOTO ENLARGEMENT



DESCRIPTION

The TC1202 is a GaAs Pseudomorphic High Electron Mobility Transistor (PHEMT) chip, which has very low noise figure and high associated gain. The device can be used in circuits up to 30 GHz and suitable for low noise application including a wide range of commercial and military applications. All devices are 100% DC tested to assure consistent quality. All bond pads are gold plated for either thermo-compression or thermo-sonic wire bonding.

ELECTRICAL SPECIFICATIONS ($T_A = 25^\circ\text{C}$)

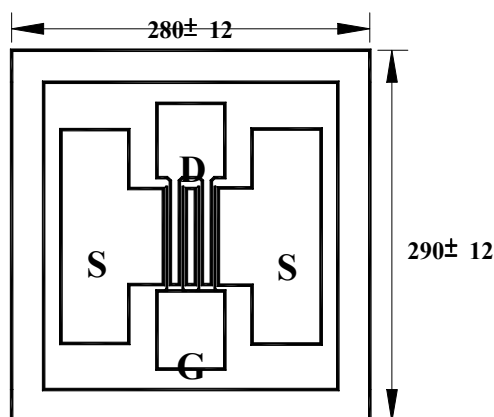
Symbol	Conditions	MIN	TYP	MAX	UNIT
NF	Noise Figure at $V_{DS} = 4 \text{ V}$, $I_{DS} = 25 \text{ mA}$, $f = 12 \text{ GHz}$		0.5	0.7	dB
G_a	Associated Gain at $V_{DS} = 4 \text{ V}$, $I_{DS} = 25 \text{ mA}$, $f = 12 \text{ GHz}$	11	12		dB
I_{DSS}	Saturated Drain-Source Current at $V_{DS} = 2 \text{ V}$, $V_{GS} = 0 \text{ V}$		90		mA
g_m	Transconductance at $V_{DS} = 2 \text{ V}$, $V_{GS} = 0 \text{ V}$		100		mS
V_p	Pinch-off Voltage at $V_{DS} = 2 \text{ V}$, $I_D = 0.6 \text{ mA}$		-1.0		Volts
BV_{DGO}	Drain-Gate Breakdown Voltage at $I_{DGO} = 0.15 \text{ mA}$	5	8		Volts
R_{th}	Thermal Resistance		120		$^\circ\text{C/W}$

Note: * For the tight control of the pinch-off voltage . TC1202's are divided into 3 groups:

(1) **TC1202P0710** : $V_p = -0.7 \text{ V}$ to -1.0 V (2) **TC1202P0811** : $V_p = -0.8 \text{ V}$ to -1.1 V (3) **TC1202P0912** : $V_p = -0.9 \text{ V}$ to -1.2 V
 In addition, the customers may specify their requirements.

ABSOLUTE MAXIMUM RATINGS ($T_A=25\text{ }^{\circ}\text{C}$) TYPICAL NOISE PARAMETERS ($T_A=25\text{ }^{\circ}\text{C}$)
 $V_{DS} = 4\text{ V}, I_{DS} = 25\text{ mA}$

Symbol	Parameter	Rating	Frequency (GHz)	NF_{opt} (dB)	G_A (dB)	Γ_{opt}		Rn/50
						MAG	ANG	
V_{DS}	Drain-Source Voltage	5 V						
V_{GS}	Gate-Source Voltage	-3.0 V	2	0.31	20.6	0.90	10	0.64
I_{DS}	Drain Current	I_{DSS}	4	0.37	17.2	0.81	20	0.45
I_{GS}	Gate Current	300 μA	6	0.41	14.8	0.74	37	0.35
P_{in}	RF Input Power, CW	20 dBm	8	0.47	13.1	0.69	57	0.29
P_T	Continuous Dissipation	400 mW	10	0.52	12.1	0.64	77	0.24
T_{CH}	Channel Temperature	175 $^{\circ}\text{C}$	12	0.58	11.4	0.58	95	0.20
T_{STG}	Storage Temperature	- 65 $^{\circ}\text{C}$ to +175 $^{\circ}\text{C}$	14	0.71	10.8	0.55	113	0.16
			16	0.88	10.4	0.52	130	0.11
			18	1.04	9.9	0.51	151	0.08

CHIP DIMENSIONS


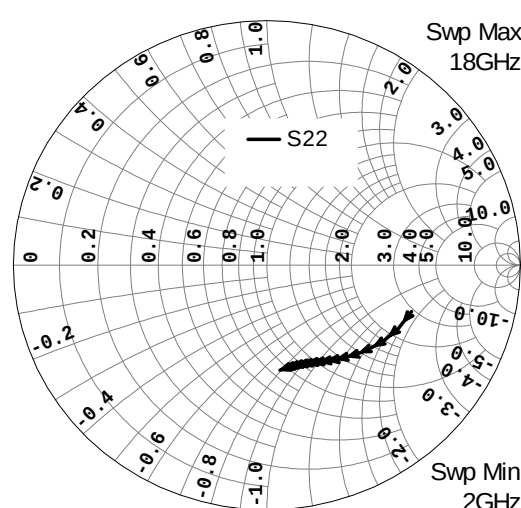
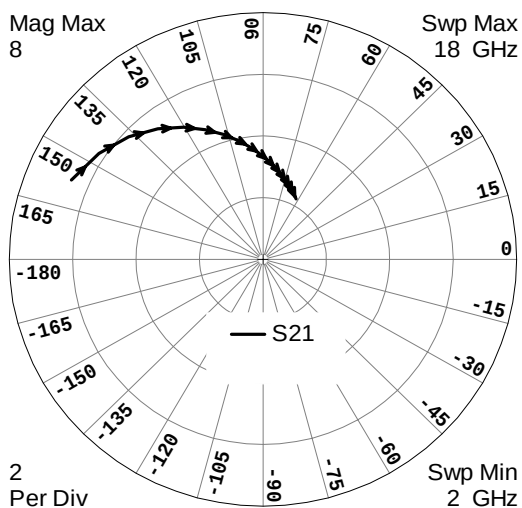
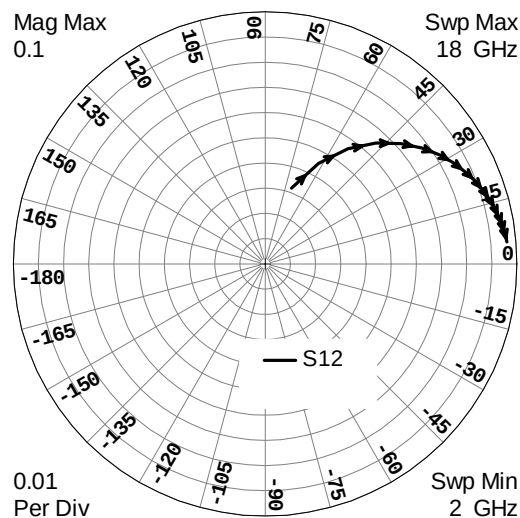
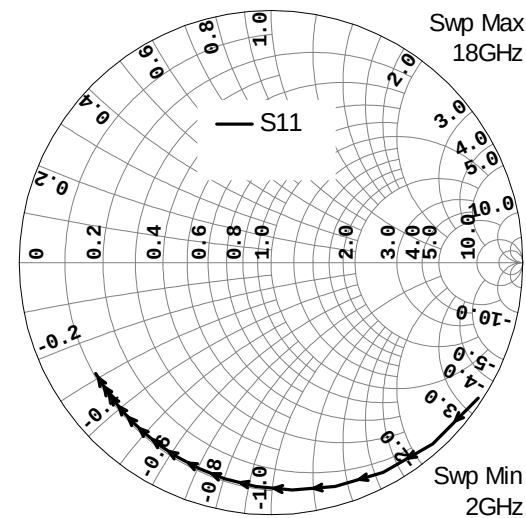
Units: Micrometers

Chip Thickness: 100

Gate Pad: 55 x 60

Drain Pad: 55 x 60

Source Pad: 55 x 169

TYPICAL SCATTERING PARAMETERS ($T_A=25\text{ }^{\circ}\text{C}$) $V_{DS} = 4\text{ V}$, $I_{DS} = 25\text{ mA}$


FREQUENCY (GHz)	S ₁₁		S ₂₁		S ₁₂		S ₂₂	
	MAG	ANG	MAG	ANG	MAG	ANG	MAG	ANG
2	0.9823	-33.16	6.5659	156.94	0.0318	70.67	0.6019	-18.38
3	0.9641	-48.24	6.2124	146.39	0.0451	61.99	0.5794	-26.63
4	0.9438	-61.87	5.8010	136.77	0.0562	54.23	0.5540	-33.99
5	0.9239	-73.98	5.3750	128.09	0.0650	47.41	0.5288	-40.46
6	0.9058	-84.62	4.9624	120.28	0.0720	41.46	0.5056	-46.12
7	0.8900	-93.94	4.5784	113.25	0.0775	36.28	0.4855	-51.07
8	0.8766	-102.10	4.2290	106.86	0.0818	31.75	0.4687	-55.44
9	0.8654	-109.26	3.9151	101.02	0.0852	27.76	0.4551	-59.33
10	0.8561	-115.58	3.6347	95.63	0.0878	24.22	0.4445	-62.83
11	0.8485	-121.18	3.3847	90.61	0.0899	21.04	0.4367	-66.01
12	0.8423	-126.18	3.1617	85.91	0.0916	18.18	0.4311	-68.94
13	0.8371	-130.67	2.9623	81.47	0.0929	15.57	0.4276	-71.66
14	0.8329	-134.73	2.7836	77.25	0.0940	13.18	0.4259	-74.21
15	0.8295	-138.41	2.6227	73.22	0.0948	10.97	0.4256	-76.61
16	0.8267	-141.77	2.4775	69.34	0.0955	8.92	0.4267	-78.89
17	0.8245	-144.86	2.3458	65.61	0.0960	7.00	0.4289	-81.07
18	0.8227	-147.71	2.2260	62.00	0.0964	5.19	0.4321	-83.16

* The data does not include gate, drain and source bond wires.

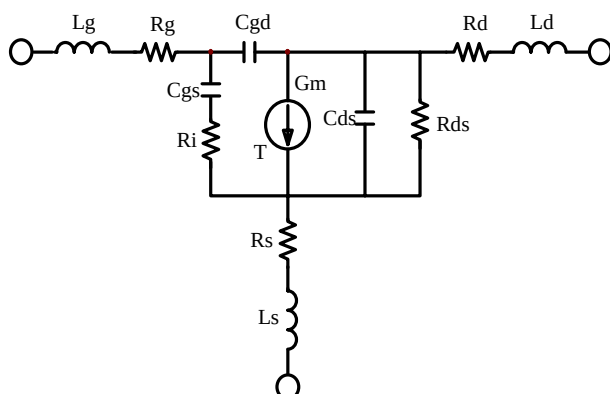
SMALL SIGNAL MODEL, $V_{DS} = 4\text{ V}$, $I_{DS} = 25\text{ mA}$

TRANSCOM, INC., 90 Dasoong 7th Road, Tainan Science-Based Industrial Park, Hsin-She Shiang, Tainan County, Taiwan, R.O.C.

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Fax: 886-6-5051602

SCHEMATI

PARAMETERS

Lg	0.045 nH	Rs	1.12 Ohm
Rg	0.79 Ohm	Ls	0.0005 nH
Cgs	0.361 pF	Cds	0.084 pF
Ri	1.47 Ohm	Rds	193.0 Ohm
Cgd	0.031 pF	Rd	0.920 Ohm
Gm	94.9 mS	Ld	0.024 nH
T	2.13 psec		

CHIP HANDLING

DIE ATTACHMENT: Conductive epoxy or eutectic die attach is recommended. Eutectic die attach can be accomplished with Au-Sn (80%Au-20%Sn) perform at stage temperature: 290°C ± 5°C; Handling Tool: Tweezers; Time: less than 1min.

WIRE BONDING: The recommended wire bond method is thermocompression bonding with 0.7 to 1.0 mil (0.018 to 0.025 mm) gold wire. Stage temperature: 220°C to 250°C; Bond Tip Temperature: 150°C; Bond Force: 20 to 30 gms depending on size of wire and Bond Tip Temperature.

HANDLING PRECAUTIONS: The user must operate in a clean, dry environment. Care should be exercised during handling avoid damage to the devices. Electrostatic Discharge (ESD) precautions should be observed at all stages of storage, handling, assembly, and testing. The static discharge must be less than 300V.